IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Atty. Dkt. No. 039153-0405 (F0945)

Draftomen

Applicant:

Uzodinma Okoroanyanwu et al.

Title:

IMPROVING SEM INSPECTION

AND ANALYSIS OF PATTERNED

PHOTORESIST FEATURES

Appl. No.:

09/820,143

Filing Date:

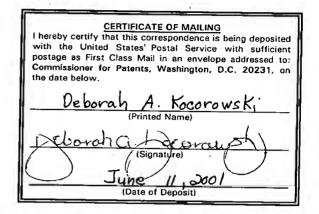
03/28/200

Examiner:

Unknown

Art Unit:

2878



TRANSMITTAL OF FORMAL DRAWINGS

Commissioner for Patents Washington, D.C. 20231

ATTENTION: DRAWING REVIEW BRANCH

Sir:

Transmitted herewith are the formal drawings (4 sheets, Figures 1-5) for the above-identified application. The Official Draftsperson is respectfully requested to approve these drawings for entry into the application.

Respectfully submitted,

**FOLEY & LARDNER** 

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